

GEMOLOGICAL INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

March 26, 2024				
IGI Report Number	LG627403350			
Description	LABORATORY GROWN DIAMOND			
Shape and Cutting Style	ROUND BRILLIANT			
Measurements	8.14 - 8.18 X 4.92 MM			
GRADING RESULTS				
Carat Weight	2.00 CARATS			
Color Grade	빗너지만한			
Clarity Grade	VS 2			
Cut Grade	IDEAL			
ADDITIONAL GRADING INFORMATION				
Polish	EXCELLENT			
Symmetry	EXCELLENT			

NONE Fluorescence 151 LG627403350 Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process and may include post-growth treatment. Type IIa

LABORATORY GROWN DIAMOND REPORT

LG627403350 Report verification at igi.org

59%

Pointed

33.9°

60.3%

PROPORTIONS

13.5%

43%

CLARITY CHARACTERISTICS

KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

 \checkmark

Medium To

Slightly Thick (Faceted)

LABORATORY GROWN DIAMOND REPORT

GRADING SCALES

CLARITY

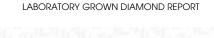
IF	VVS ¹⁻²	VS ¹⁻²	SI ¹⁻²	1 ¹⁻³
Internally	Very Very	Very	Slightly	Included
Flawless	Slightly Included	Slightly Included	Included	

COLOR

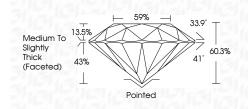
D E F G H I J Faint Very Light L	Light
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1051 LG627403350

Sample Image Used



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ADDITIONAL GRADING INFORMATION

Type IIa

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	(G) LG627403350
Comments: This Laboratory C created by Chemical Vapor process and may include po	Deposition (CVD) growth

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